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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Re Application of

CHENG et al.

Confirmation No. 4755

Serial No. 10/705,500

Examiner: Malsawma, L.

Filed: November 12, 2003

Art Unit: 2825

For: METHOD FOR PREVENTING TO FORM A SPACER UNDERCUT IN SEG PRE-CLEAN PROCESS

TRANSMITTAL LETTER

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir:

Submitted herewith for filing in the U.S. Patent and Trademark Office is the following:

- (1) Response and Amendment.

If an extension of time is required to make the enclosed response timely, then please grant the required number of months. Please charge any required fee for an extension of time or otherwise, or credit any overpayment, in connection with this matter to Deposit Account No. 14-0112.

Respectfully submitted,  
NATH & ASSOCIATES PLLC

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Date: November 12, 2004

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Appl. No. 10/705,500

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

Appl. No. : 10/705,500  
Applicant : Ya-Lun Cheng  
Filed November 12, 2003  
Title METHOD FOR PREVENTING TO FORM A SPACER  
UNDERCUT IN SEG PRE-CLEAN PROCESS  
TC/A.U. 2825  
Examiner MALSAWMA, LALRINFAMKIM HMAR  
Docket No. 82546

Honorable Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

**RESPONSE AND AMENDMENT**

Sir:

In response to the Official Action mailed 12 August 2004, Applicants respectfully request that the Examiner reconsider the amended application according to the following remarks.

Please amend the above-identified application as follows:

**Amendments to the Specification** begin on page 2 of this paper.

**Amendments to the Claims** begin on page 3 of this paper.

**Remarks/Arguments** begin on page 7 of this paper.